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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Shuichi OKAWA et al.

Group Art Unit: 1765

Application No.: 10/553,677

Docket No.: 125685

Filed: October 17, 2005

For: MASK MATERIAL FOR REACTIVE ION ETCHING, MASK, AND DRY
ETCHING METHOD

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,


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JAO:LMS/hjr

Date: May 9, 2006

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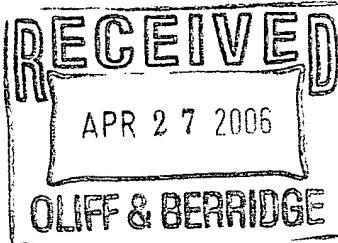
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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/553,677	10/17/2005	1765	900	125685	7	20	1

25944
OLIFF & BERRIDGE, PLC
P.O. BOX 19928
ALEXANDRIA, VA 22320



CONFIRMATION NO. 1829

FILING RECEIPT



OC000000018590113

Date Mailed: 04/26/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Correction on

2nd Page



Assignment For Published Patent Application

TDK CORPORATION, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/08232 06/11/2004

Foreign Applications

JAPAN 2003-188468 06/30/2003

If Required, Foreign Filing License Granted: 04/20/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/553,677**

Projected Publication Date: 07/27/2006

Non-Publication Request: No

Early Publication Request: No

Title

Mask material for reactive ion etching, mask and dry etching method

insert comma

Preliminary Class

438

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